

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of	
David W. SHERRER et al	Group Art Unit: 1772
Application No: 09/519,165	Examiner: William P. Watkins, III
Filed: March 6, 2000	Confirmation No: 8879
FOR: SINGLE MASK LITHOGRAPHIC) PROCESS FOR PATTERNING) MULTIPLE TYPES OF SURFACE) FEATURES	

AMENDMENT

Commissioner for Patents P.O. Box 1450 Alexandria, Virginia 22313-1450

Sir:

In response to the Official Action mailed January 13, 2004, applicants submit the following amendments and remarks.

Amendments to the claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks begin on page 7 of this paper.

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